



David Cooper obtained his Ph.d. from the University of Cambridge in the subject of dopant profiling by off-axis electron holography. He has since worked at CEA LETI developing new techniques to anticipate the future needs of the semiconductor industry and currently holds the post Senior Staff Scientist. Between 2012 and 2018, David was the holder of a ERC starting grant which focused on the optimization of electron holography and in-situ methods. He currently works on most TEM based techniques and is interested in correlation between TEM and other complimentary methods. He has published more than 150 peer reviewed papers.